

UMX800金相显微镜Metallographic Microscope

特点Feature

- UF2 无限远色差校正光学系统

明场、暗场、偏光观察方式

长工作距离，明暗场平场消色差物镜

100W 明亮照明，图像更加锐利

快速移动载物台减少观察时间

宽视野正像观察，提高操作舒适性
- UF2 infinity system

Brightfield,darkfield and polarizing

Longer working distance objective

High-brightness Illuminator 100W

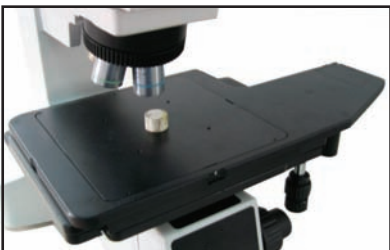
The large stage 200x200mm

Erecting system viewing



永丰 UF2 光学系统具有更长得工作距离，全新明暗场平场物镜将国产显微镜提到了一个新的高度。

USFEN UF2 optics provide high NA and a longer working distance. UF optics deliver bright,high-resolution images.



宽视野正像观察使试样与像移动方向一致，减少了扫描标本和确定目标所需时间。

Wide image fields and erecting system reduce the time needed to scan your specimens.

技术参数

光学系统	无限远校正系统
观察方式	明场，暗场，偏光
放大倍数	50X,100X,200X,500X,800X
聚焦	微调最小刻度 1um
照明	12V100W
载物台	200x200mm
目镜	10X 视野数 22mm
物镜转换器	5 孔
物镜	5X/0.17,WD12
	10X/0.25,WD6.0
	20X/0.40,WD5.0
	50X/0.70,WD2.0
	80X/0.80,WD1.0
视场光阑	1 个
孔径光阑	1 个
电源	90-240V
尺寸	430X590X500mm
重量	26Kg

Specifications

Optics	UF2 infinity system
Observation method	Brightfield, darkfieldpolarizing
Magnification	50X,100X,200X,500X, 800X
Focus	Graduation:1um
Illuminator	12V100W
Stage	200x200mm
Eyepiece	10X(F.N22)
Nosepiece	5
Objective	5X/0.17,WD12
	10X/0.25,WD6.0
	20X/0.40,WD5.0
	50X/0.70,WD2.0
	80X/0.80,WD1.0
Field diaphram	1
Mirror	1
Power consumption	90-240V
Dimensions	430X590X500mm
Weight	26Kg